

ACKNOWLEDGEMENT RECEIPT

Electronic Version 1.1

Stylesheet Version v1.1.1

Title of Invention

Method of Selective Deposition of Heavily Doped Epitaxial SiGe

Submission Type : Information Disclosure Statement

Application Number:

10/683937



EFS ID:

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Attorney Docket Number: AMAT8539TSGEPIRKK

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File Listing:

Doc. Name	File Name	Size (Bytes)	Date Produced (yyyymmdd)
us-ids	AMAT8539TSGEPIRKK-usidst.xml	1985	2005-01-28
us-ids	us-ids.dtd	7763	2005-01-28
us-ids	us-ids.xsl	12026	2005-01-28
package-data	AMAT8539TSGEPIRKK-pkda.xml	1710	2005-01-28
package-data	package-data.dtd	27025	2005-01-28
package-data	us-package-data.xsl	19263	2005-01-28
Total files size		69772	

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